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2-3-03

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

JC675 U.S. PTO
10/027951
12/19/01

In re Application of:

Donald L. Yates

Serial No.: ~~Not yet assigned~~ 10/027951

Filed: December 19, 2001

For: METHOD OF REDUCING WATER
SPOTTING AND OXIDE GROWTH ON A
SEMICONDUCTOR STRUCTURE

Examiner: ~~Unknown~~ MARKOFF

Group Art Unit: ~~Unknown~~ 1746

Attorney Docket No.: 3375.6US
(95-0999.4)

NOTICE OF EXPRESS MAILING

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Date of Deposit with USPS: December 19, 2001

Person making Deposit: Blake Johnson

INFORMATION DISCLOSURE STATEMENT

Box PATENT APPLICATION
Commissioner for Patents
Washington, D.C. 20231

Sir:

The present application is a continuation of application Serial No. 08/814,900, filed March 12, 1997, pending..

Pursuant to M.P.E.P. 2001.06(b), the Examiner is respectfully requested to consider the information of record in the prior application, and to confirm in the first Office Action on the merits that such art has in fact been reviewed. A PTO-1449 form listing all of the information of record in the prior application is enclosed herewith.

Attorney Docket No. 3375.6US (95-0999.4)

This Information Disclosure Statement is filed within three (3) months of the filing date of the above-identified application, and no certification pursuant to 37 C.F.R. § 1.97(c) or a fee pursuant to 37 C.F.R. 1.17(p) is required.

Respectfully submitted,



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Date: December 19, 2001
JRD/jml
Enclosure: Form PTO-1449

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|---|--|--|---|--|---|--|
| Form PTO-1449 INFORMATION DISCLOSURE CITATION IN AN APPLICATION <i>(Use several sheets if necessary)</i> | | | Docket Number (Optional) 3375.6US (95-0999.4) | | Application Number Not yet assigned | |
| | | | Applicant Donald L. Yates | | | |
| | | | Filing Date December 19, 2001 | | Group Art Unit Unknown | |

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| OTHER DOCUMENTS | | (Including Author, Title, Date, Pertinent Pages, Etc.) |
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| | | <i>Handbook of Semiconductor Wafer Cleaning Technology</i> , editor W. Kern, Noyes Publications, pp. 131-51 and 405-15. |
| | | <i>Koppenbrink et al., Particle Reduction on Silicon Wafers as a Result of Isopropyl Alcohol Vapor Displacement Drying after Wet Processing, Particles on Surfaces 2</i> , editor K. Mittal, Plenum Press. pp. 235-43. |
| | | <i>Marra et al., Physical Principles of Marangoni Drying</i> , Langmuir, Vol. 7, No. 11, pp. 2748-55. |

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| EXAMINER | DATE CONSIDERED |
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EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP § 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to the applicant.

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| | | | Applicant Donald L. Yates | | | |
| | | | Filing Date December 19, 2001 | | Group Art Unit Unknown | |

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| | | Leenaars et al., <i>Marangoni Drying: A New Extremely Clean Drying Process</i> , Langmuir, Vol. 6, No. 11, pp. 1701-03. |
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